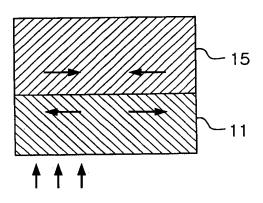
METHOD FOR MANUFACTURING GALLIUM NITRIDE(GaN) BASED SINGLE

CRYSTALLINE SUBSTRATE
Inventor: NA, Jeong Seok et al.
Docket No. 2336-195

1/3



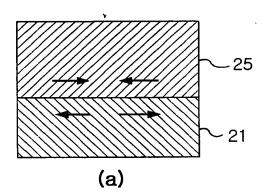
PRIOR ART

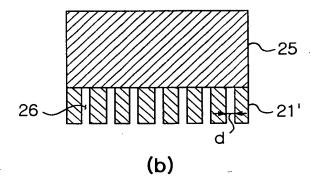
FIG. 1

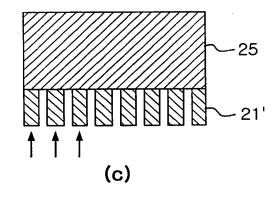
METHOD FOR MANUFACTURING GALLIUM NITRIDE(GaN) BASED SINGLE

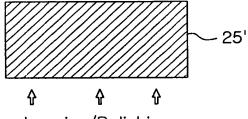
CRYSTALLINE SUBSTRATE

Inventor: NA, Jeong Seok et al.
Docket No. 2336-195
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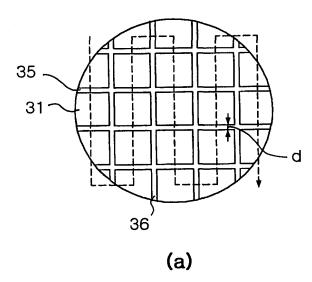


Lapping/Polishing

(d)

FIG. 2

METHOD FOR MANUFACTURING GALLIUM NITRIDE(GaN) BASED SINGLE CRYSTALLINE SUBSTRATE Inventor: NA, Jeong Seok et al. Docket No. 2336-195 3/3



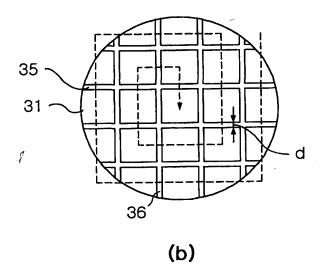


FIG. 3